

Form 1449 (Modified) Information Disclosure Statement By Applicant (Use Several Sheets if Necessary)	Atty Docket No. CISC831 Application No.: 10/630,582 Inventor Fausto Meli Group 1326 Filing Date July 29, 2003 Mailing Date July 7, 2004
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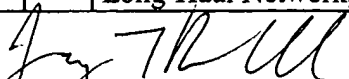
U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub-Class	Filing Date
JTR	AA	6,433,921 B1	08/13/02	Wu et al.	359	334	02/15/01
JTR	AB	6,587,260 B2	07/01/03	Kikuchi et al.	359	334	08/24/01

Foreign Patent or Published Foreign Patent Application

Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub-class	Translation	
							Yes	No
JTR	AC	2001197006A	07/19/01	JP			Abst	
JTR	AD	03/034111 A2	04/24/03	WO			Yes	

Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
JTR	AE	Kaneko, Akimasa et al., "Design and Applications of Silica-Based Planar Lightwave Circuits," IEEE Journal of Selected Topics in Quantum Electronics, Vol. 5, No. 5, September/October 1999, pp. 1227-1236.
JTR	AF	Ramaswami, R. et al. "Optical Networks: A Practical Perspective," pp. 112-115, 1998.
JTR	AG	Tomkos, I. et al., "Ultra-Long-Haul DWDM Network with 320x320 Wavelength-Port 'Broadcast & Select' OXCs," European Conference on Optical Communication, September 2002, Copenhagen, Denmark, post-deadline paper PD2.1.
JTR	AH	Tomkos, I. et al., "80x10.7 Gb/s Ultra-Long-Haul (4200+ km) DWDM Network with Reconfigurable 'Broadcast & Select' OADMs," Optical Fiber Communication Conference 2002, post-deadline paper FC1.
JTR	AI	Vasilyev, M. et al., "Transparent Ultra-Long-Haul DWDM Networks with 'Broadcast & Select' OADM/OXC Architecture," Journal of Lightwave Technology, 2003, 20, 2661.
JTR	AJ	Vasilyev, M. et al., "Broadcast & Select OADM in 80x10.7 Gb/s Ultra-Long-Haul Network," IEEE Photon. Technol. Lett., 2003, 15, 332.
Examiner	<div>  </div>	
	Date Considered	10/30/05

Examiner Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.